PROCEEDINGS OF SPIE

Organic Photonic Materials and Devices XXI

Christopher E. Tabor François Kajzar Toshikuni Kaino Editors

5–7 February 2019 San Francisco, California, United States

Sponsored and Published by SPIE

Volume 10915

Proceedings of SPIE 0277-786X, V. 10915

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Organic Photonic Materials and Devices XXI, edited by Christopher E. Tabor, François Kajzar, Toshikuni Kaino, Proc. of SPIE Vol. 10915, 1091501 · © 2019 SPIE · CCC code: 0277-786X/19/\$18 · doi: 10.1117/12.2531136

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Author(s), "Title of Paper," in *Organic Photonic Materials and Devices XXI*, edited by Christopher E. Tabor, François Kajzar, Toshikuni Kaino, Proceedings of SPIE Vol. 10915 (SPIE, Bellingham, WA, 2019) Seven-digit Article CID Number.

ISSN: 0277-786X

ISSN: 1996-756X (electronic)

ISBN: 9781510624726

ISBN: 9781510624733 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445

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